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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Customer Number: 20277

Naoteru MATUSBARA, et al. : Confirmation Number: 4231

Application No.: 10/664,875 : Group Art Unit: 2811

Filed: September 22, 2003 : Examiner: Not Yet Assigned

For: SEMICONDUCTOR DEVICE INCLUDING INTERCONNECTS FORMED BY

DAMASCENE PROCESS AND MANUFACTURING METHOD THEREOF

INFORMATION DISCLOSURE STATEMENT

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed more than three months after the U.S. filing date AND after the mailing date of the first Office Action on the merits, but before the mailing date of a Final Rejection or Notice of Allowance.

CERTIFICATION PARAGRAPH

The undersigned certifies that each item of information contained in this Information Disclosure Statement was first cited in a communication from a foreign patent office in a

10/664,875

counterpart foreign application not more than three months prior to the filing of this Information

Disclosure Statement as described in 37 CFR 1.97(e)(1).

Each non-English language reference was cited in a corresponding foreign application

search report or office action and its relevance discussed therein. A copy of the foreign search

report or office action, together with an English language version thereof, is attached for the

Examiner's information.

Please charge any shortage in fees due in connection with the filing of this paper,

including extension of time fees, to Deposit Account 500417 and please credit any excess fees to

such deposit account.

Respectfully submitted,

McDERMOTT WILL & EMERY LLP

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Date: April 24, 2006

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SHEET <u>1</u> OF <u>1</u>

INFORMATION DISCLOSURE CITATION IN AN APPLICATION					ATTY. DOCKET NO. 065933-0044		rial no. 1/ 664,875			
					APPLICANT Naoteru MATUSBARA, et al.					
	((PT	O-1449)		FILING DATE September 22, 2003		ROUP 811			
U.S. PATENT DOCUMENTS										
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code2 (1 known)		Publication Date MM-DD-YYYY		Name of Patentee or Applicant of Cited Document		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
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			Chinese Office Action, Date of Dispatch: February 24, 2006							
						- 				
		EX	AMINER		DATE CONSIDERED					

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.